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School of Electrical Engineering, Xi'an Jiaotong University, Xi'an, China

2P-105 Magnesium Alloy Oxidation Using Atmospheric Pressure Plasma Jet

H. J. Jeong, J. K. Lee

Next Generation Product Research Group, POSCO, Pohang, South Korea

2P-106 Controlled Preparation of Alkaline Anion- Exchange Membranes by Plasma Technology

J. Hu

Institute of Plasma Physics, Chinese Academy of Sciences, Hefei, Anhui, China

2P-107 The Ecton Model of Unipolar Arcing at Fine-Structured Surface

S. A. Barengolts¹, G. A. Mesyats², M. M. Tsventoukh²

¹*Prokhorov General Physics Institute RAS, Moscow, Russian Federation*

²*Lebedev Physical Institute RAS, Moscow, Russian Federation*

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Y. Guo

College of Sciences, Donghua University, Shanghai, China

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R. Torigoe¹, T. Urakawa¹, D. Yamashita¹, H. Matsuzaki¹, G. Uchida¹, K. Koga^{1,2}, M. Shiratani^{1,2}, Y. Setsuhara^{3,2}, M. Sekine^{4,2}, M. Hori^{4,2}

¹*Kyushu University, Fukuoka, Japan*

²*JST, CREST, Saitama, Japan*

³*Osaka University, Osaka, Japan*

⁴*Nagoya University, Nagoya, Japan*

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S. Mitea¹, M. D. Bowden¹, N. S. J. Braithwaite¹, M. Zeleznik², P. W. May², N. A. Fox², C. Fowler³, B. Stevens^{3,4}

¹*Department of Physical Sciences, The Open University, Milton Keynes, United Kingdom*

²*School of Chemistry, University of Bristol, Bristol, United Kingdom*

³*Micro- and Nano-Technology Centre, STFC Rutherford Appleton Laboratory, Didcot, United Kingdom*

⁴*School of Science and Technology, Nottingham Trent University, Nottingham, United Kingdom*

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X. Li, R. Li, S. Jia

Xi'an Jiaotong University, Xi'an, China

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G. Wu

Department of Physics and Materials Science, City University of Hong Kong, Hong Kong, China

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Y. Shi, D. Cheng, Z. Zong, Y. Xie

PPAL, Applied Physics Department, College of Science, Donghua University, Shanghai, China

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K. Shimizu, M. G. Blajan, H. Fukunaga

Innovation and Joint Research Center, Shizuoka University, Hamamatsu, Japan

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E. Teke¹, H. Varol², F. Bozduman³, A. Gulec⁴, L. Oksuz⁵, S. Manolache⁶, E. Camurlu⁷, C. Kurbanoglu⁸

¹*Physics, Erdogan Teke, Isparta, Turkey*

²*Machine, Hatice Varol, Isparta, Turkey*

RETARDATION OF DEGRADATION OF BIOMEDICAL MAGNESIUM ALLOY BY PLASMA-BASED DEPOSITION TECHNIQUE*

Guosong Wu, James M, Ying Zhao and Paul K. Chu
*Department of Physics and Materials Science, City
University of Hong Kong,
Tat Chee Avenue, Kowloon, Hong Kong*

Magnesium-based materials have been reconsidered as revolutionary metallic biomaterials due to their favorable biodegradation and Young's modulus similar to that of human bone. However, most magnesium alloys suffer from a biodegradation rate that is too high, particularly in the early stage. Hydrogen bubbles and surface alkalization can also influence tissue growth during the degradation process. Therefore, it is necessary to modify the surface of Mg alloys in order to mitigate degradation in the early stage to ensure proper tissue healing and growth. In this work, ceramic coatings are deposited on biodegradable magnesium alloys by sputtering to reduce the electrochemical activity in the simulated physiological environment. AlO_xN_y ceramic coatings are successfully deposited on AZ31 magnesium alloys with Al or Ti interlayers. Polarization tests and electrochemical impedance spectroscopy (EIS) are conducted to evaluate the corrosion resistance in the cell culture medium. The AlO_xN_y ceramic coating can effectively reduce the electrochemical activity of AZ31 and significantly improve the surface mechanical properties. The Ti interlayer increases corrosion of Mg alloy due to the presence of defects. The Al interlayer compromises the surface mechanical properties, but does not produce negative effects on the degradation in the cell culture media.

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